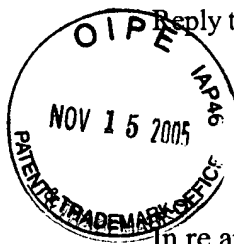


Zfw

U.S. Patent Application No. 10/791,014
Reply to Office Action of August 17, 2005

Attorney Docket No. TSMC2000-488 / 24061.596
Customer No. 42717



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Chung-Shi Liu et al.

Serial No.: 10/791,014

Filed: March 2, 2004

For: PREVENTION OF POST CMP
DEFECTS IN CU/FSG PROCESS

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Group Art Unit: 2826

Examiner: Fetsum Abraham

Commissioner for Patents
Mail Stop Amendment
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

In response to the Office action of August 17, 2005, please amend the above-identified application as follows:

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims which begins on page 3 of this paper.

Remarks begin on page 8 of this paper.